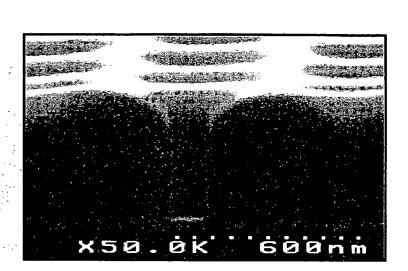
Attorney Docket: 30205/37328
Invertors: Min Ho Jung et al.
Title Additive for Photoresist Composition for Resk (Swe Process")
Sheet 1 of 2



1 Just 16m, 18 H

Fig.1

Attorney Docket: 30205/37328

Inventor Min Ho Jung et al.

Title: Title: Process
Sheet 2 of 2

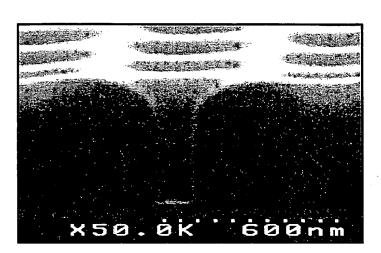


Fig.2